

L Number	Hits	Search Text	DB	Time stamp
-	51785	(mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:04
-	25136	((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:05
-	26	((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/26 16:28
-	922	((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4acrylate or \$4acrylate)) not (((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/26 16:27
-	26	((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/26 16:32
-	854	((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4acrylate or \$4acrylate)) not (((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/26 16:32

-	6	(((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3 or photoresist) same (scrib\$4 or cut\$4 or mark\$4 or scrap\$4)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:12
-	1560	(mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:55
-	308	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4) adj3 (mask\$3 or resist\$3 or photoresist)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:10
-	495	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off) near3 (mask\$3 or resist\$3 or photoresist)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:11
-	511	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/06/03 09:12
-	24	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist) same (seal\$3)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:13
-	1	(maskant or mask) and line adj sealant same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:17
-	0	(maskant or mask) and line adj sealer same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:18
-	92	(216/42,44,47,48,101-102 or 430/320,323-324 or 205/122,135,153,188,320,324).ccls. and seal\$3 same mask\$3	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:18
-	145	(IRACURE adj "1700") or (IRACURE adj "1700")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:21
-	23	((IRACURE adj "1700") or (IRACURE adj "1700")) and (wax or (synergist and triethanolamine))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:24
-	3	((IRACURE adj "1700") or (IRACURE adj "1700")) and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or "W/cm.sup.2" or "W/m.sup.2")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:47
-	762	(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off) and \$4acrylate and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or \$1"W/cm.sup.2" or \$1"W/m.sup.2")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 16:13

-	40	(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off) and \$4acrylate.ti,ab. and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or \$1"W/cm.sup.2")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:49
-	6	(((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3 or photoresist) same (scrib\$4 or cut\$4 or mark\$4 or scrap\$4)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:50
-	25	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scrib\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist) same (seal\$3)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:52
-	1	(maskant or mask) and line adj sealant same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:53
-	0	(maskant or mask) and line adj sealer same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:54
-	95	(216/42,44,47,48,101-102.ccls. or 430/320,323-324.ccls. or 205/122,135,153,188,320,324.ccls.) and seal\$3 same mask\$3	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:59
-	170	(IRGACURE adj "1700") or (IRACURE adj "1700")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/10/13 21:22
-	29	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (wax or (synergist and triethanolamine))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 10:02
-	3	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or "W/cm.sup.2" or "W/m.sup.2")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:48
-	41	(mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off) and \$4acrylate.ti,ab. and (cur\$3 or expos\$3 or light\$3 or UV or ultraviolet or actinic or radiat\$3) same (\$5watt adj per adj square adj \$5meter or \$1"W/cm.sup.2")	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:50
-	7	(((((mask\$3 or resist\$3 or photoresist) same ((etch\$3 or chemical\$2 adj mil\$3 or deoxidiz\$3 or anodiz\$3) and metal)) and (mask\$3 or resist\$3 or photoresist) same (aluminum or "Al" or steel or titanium or "Ti")) and (mask\$3 or resist\$3 or photoresist) same (\$4urethane adj3 \$4acrylate or \$4urethane adj3 \$4acrylate)) and (mask\$3 or resist\$3 or photoresist) same (peel\$4 or pull\$4 or remov\$4 or lift\$3 adj off)) and (mask\$3 or resist\$3 or photoresist) same (scrib\$4 or cut\$4 or mark\$4 or scrap\$4)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:51

-	25	((mask\$3 or resist\$3 or photoresist) same ((deoxidiz\$3 or anodiz\$3) and metal)) and (peel\$4 or remov\$4 or scribe\$4 or pull\$4 or lift\$3 adj off or cut\$4 or scrap\$4) near3 (mask\$3 or resist\$3 or photoresist) same (seal\$3)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:52
-	1	(maskant or mask) and line adj sealant same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:53
-	0	(maskant or mask) and line adj sealer same ((deoxidiz\$3 or anodiz\$3) and metal)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:54
-	99	(216/42,44,47,48,101-102.ccls. or 430/320,323-324.ccls. or 205/122,135,153,188,320,324.ccls.) and seal\$3 same mask\$3	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 09:59
-	31	((IRGACURE adj "1700") or (IRACURE adj "1700")) and (wax or (synergist and triethanolamine))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2004/01/16 10:02